

| | Type | Hits | Search Text | DBs | Time Stamp | Er ro r m e n t s | Er ro r m e n t s |
|---|------|------|---|---|------------------|--|--|
| 1 | BRS | 51 | (phenyltetrazole) and etch\$3 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 11:59 | | 0 |
| 2 | BRS | 28 | ((phenyltetrazole) and etch\$3) and @pd<=20010726 | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 11:34 | | 0 |
| 3 | BRS | 0 | ((phenyltetrazole) and etch\$3) and @pd<=20010726) AND 438/\$.CCLS. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 11:34 | | 0 |
| 4 | BRS | 0 | ((phenyltetrazole) and etch\$3) and @pd<=20010726) and 438/\$.ccls. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 11:34 | | 0 |
| 5 | BRS | 0 | ((phenyltetrazole) and etch\$3) and @pd<=20010726) and 252/\$.ccls. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 11:35 | | 0 |
| 6 | BRS | 0 | ((phenyltetrazole) and etch\$3) and @pd<=20010726) and 216/\$.ccls. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 11:35 | | 0 |
| 7 | BRS | 0 | ((phenyltetrazole) and etch\$3) and @pd<=20010726) and 134/\$.ccls. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 11:42 | | 0 |
| 8 | BRS | 2 | "20030064596" | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 11:44 | | 0 |

| | Type | Hits | Search Text | DBs | Time Stamp | Error Count | Detail |
|----|------|------|--|---|------------------|-------------|--------|
| 9 | BRS | 2 | KURII-YOSHIHIRO.in. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 11:46 | 0 | |
| 10 | BRS | 2 | KAMEDA-ETSUJI.in. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 11:47 | 0 | |
| 11 | BRS | 28 | NAKAMURA-SACHIKO.in. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 11:47 | 0 | |
| 12 | BRS | 15 | (phenyltetrazole) and etch\$3 and (sulfonic or sulfosalicylic) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 12:38 | 0 | |
| 13 | BRS | 8 | ("H.sub.2 SO.sub.4" or sulfuric) and (peroxide or "hydrogen peroxide" or "H.sub.2 O.sub.2") and (phenyltetrazole) and etch\$3 and (sulfonic or sulfosalicylic) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 12:42 | 0 | |
| 14 | BRS | 0 | (("H.sub.2 SO.sub.4" or sulfuric) and (peroxide or "hydrogen peroxide" or "H.sub.2 O.sub.2") and (phenyltetrazole) and etch\$3 and (sulfonic or sulfosalicylic) and (Cu or copper)) and 438/\$.ccls. | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 12:43 | 0 | |
| 15 | BRS | 5 | ("H.sub.2 SO.sub.4" or sulfuric) and (peroxide or "hydrogen peroxide" or "H.sub.2 O.sub.2") and (phenyltetrazole) and etch\$3 and (sulfonic or sulfosalicylic) and (Cu or copper) | USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB | 2004/02/04 16:25 | 0 | |